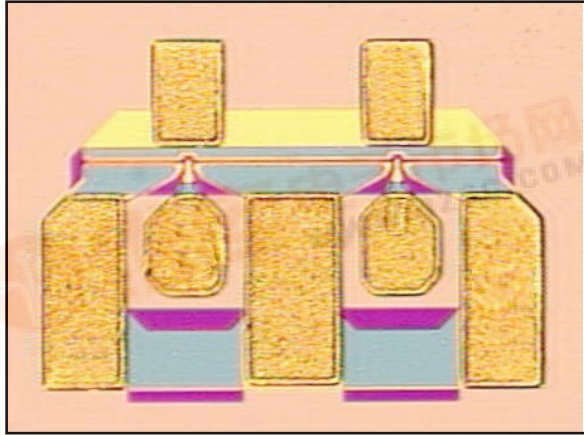


300um Discrete pHEMT TGF4350-EPU

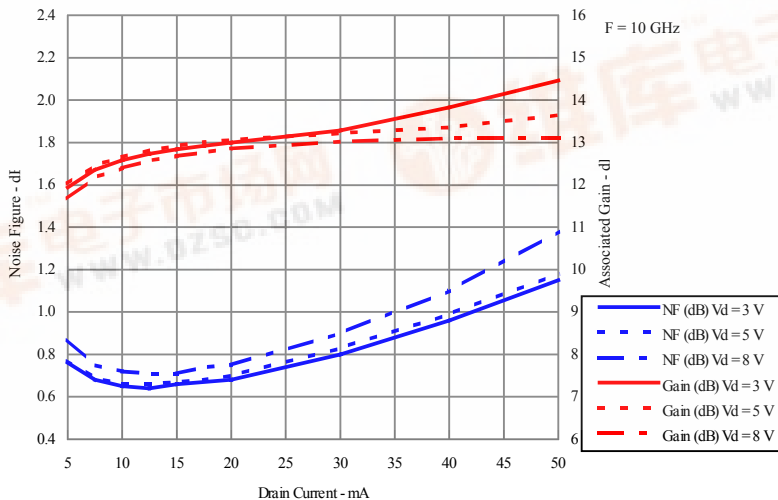
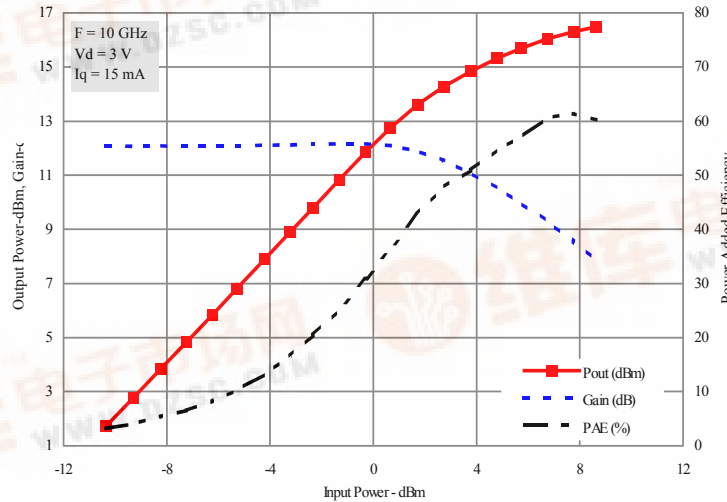


Key Features and Performance

- 0.25um pHEMT Technology
- DC 22 GHz Frequency Range
- 1.2 dB NF, 14.5 dB Associated Gain at 10 GHz, 3V Operation
- Floating Source Configuration
- Chip Dimensions 0.5080 mm x 0.4064 mm

Primary Applications

- Low Noise amplifiers



Electrical Characteristics

RECOMMENDED MAXIMUM RATINGS

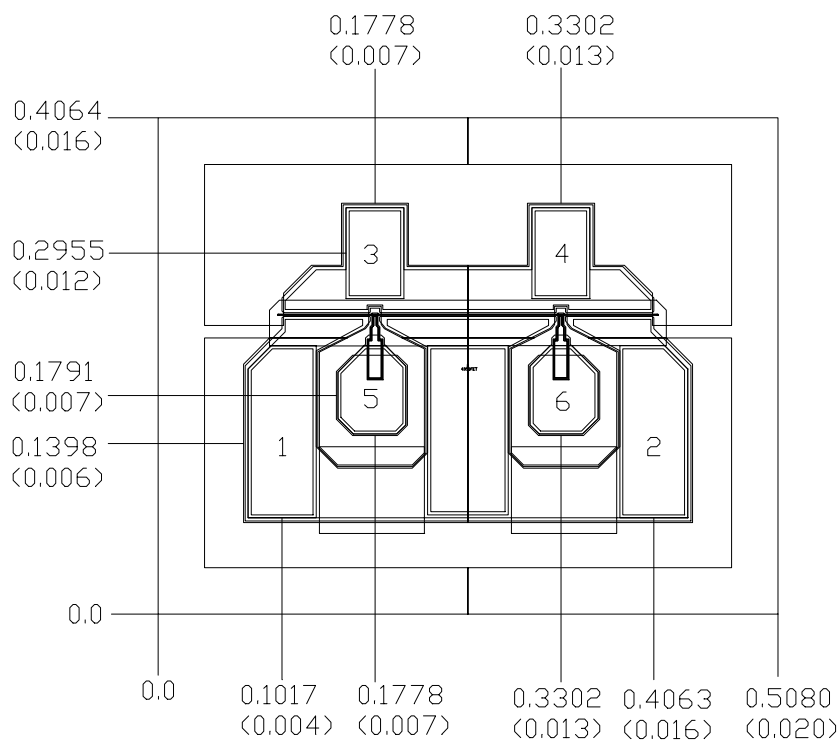
Symbol	Parameter	Value	Notes
V ⁺	Positive Supply Voltage	7 V	
I ⁺	Positive Supply Current	.085A	3/
P _D	Power Dissipation	0.6 W	
P _{IN}	Input Continuous Wave Power	20 dBm	
T _{CH}	Operating Channel Temperature	150 °C	1/, 2/
T _M	Mounting Temperature (30 seconds)	320 °C	
T _{STG}	Storage Temperature	-65 °C to 150 °C	

- 1/ These ratings apply to individual FET
- 2/ Junction operating temperature will directly affect the device mean time to failure (MTTF). For maximum life it is recommended that junction temperatures be maintained at the lowest possible levels.
- 3/ Nominal value of Idss

DC PROBE TESTS (T_A = 25 °C ± 5°C)

Symbol	Parameter	Minimum	Maximum	Value
Idss	Saturated Drain Current (info only)	30	141	mA
V _{P1-5}	Pinch-off Voltage	-1.5	-0.5	V
BV _{GS1}	Breakdown Voltage gate-source	-30	-8	V
BV _{GDI-5}	Breakdown Voltage gate-drain	-30	-8	V

Mechanical Drawing



Units: millimeters (inches)

Thickness: 0.1016 (0.004)

Chip edge to bond pad dimensions are shown to center of bond pad
chip size tolerance: +/- 0.051 (0.002)

Bond Pad #1,#2 (Source)	0.051 x 0.136 (0.002 x 0.005)
Bond Pad #3,#4 (Drain)	0.042 x 0.069 (0.002 x 0.003)
Bond Pad #5,#6 (Gate)	0.051 x 0.067 (0.002 x 0.003)

Process and Assembly Notes

***This device should be attached using conductive epoxy only.
Contact factory for additional details as required.***

Component placement and adhesive attachment assembly notes:

- vacuum pencils and/or vacuum collets preferred method of pick up
- avoidance of air bridges during placement
- force impact critical during auto placement
- organic attachment can be used in low-power applications
- curing should be done in a convection oven; proper exhaust is a safety concern
- microwave or radiant curing should not be used because of differential heating
- coefficient of thermal expansion matching is critical

Interconnect process assembly notes:

- thermosonic ball bonding is the preferred interconnect technique
- force, time, and ultrasonics are critical parameters
- aluminum wire should not be used
- discrete FET devices with small pad sizes should be bonded with 0.0007-inch wire
- maximum stage temperature: 200°C